

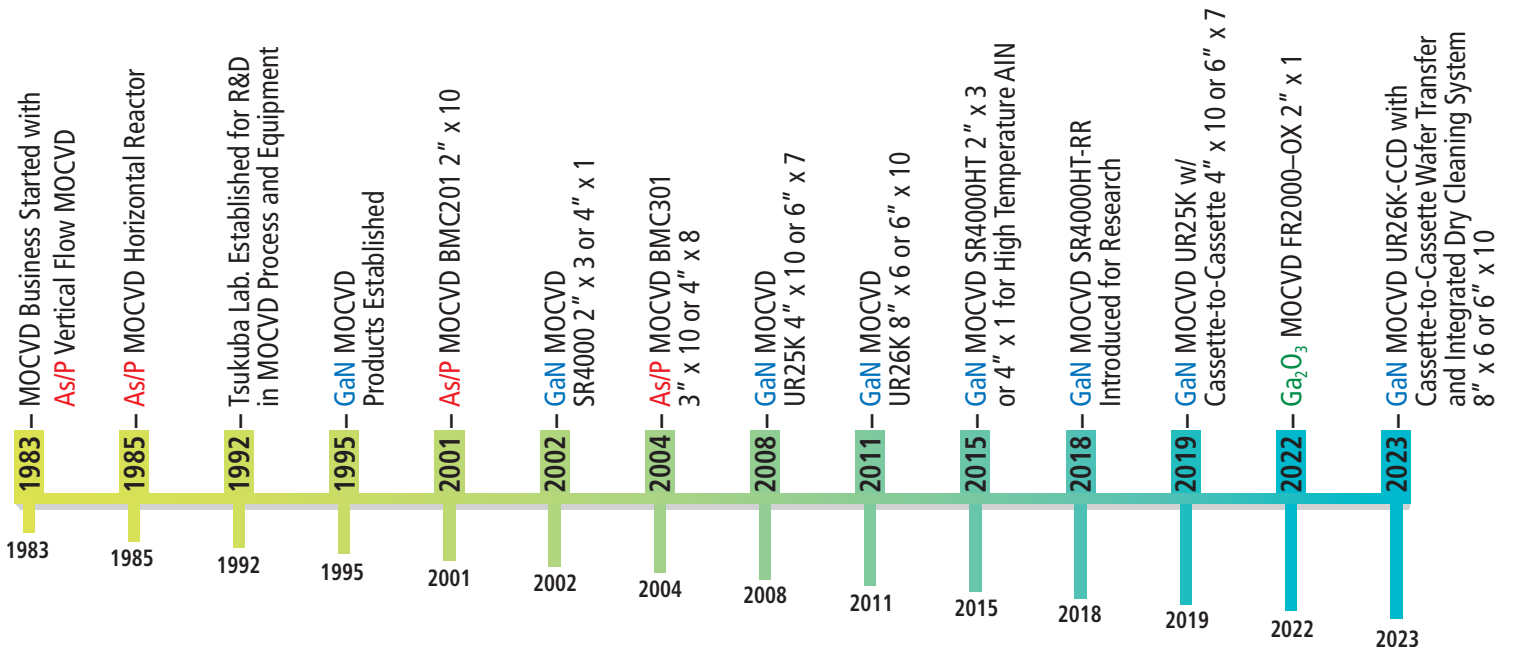
Taiyo Nippon Sanso MOCVD Equipment

Global Commitment and Proven Performance



Taiyo Nippon Sanso Corporation (TNSC) was the first company to develop and introduce its own commercial metal organic chemical vapor deposition (MOCVD) systems in 1983. TNSC equipment has received praise for its world-class performance and stability. TNSC is also uniquely qualified to provide total solutions for MOCVD applications, including MOCVD equipment, purification and abatement solutions, specialty gases, and gas handling equipment.

MOCVD Innovations



Over Six Hundred (600) Installations Worldwide

Select List of Public Installations

- Sandia National Laboratories, United States
- North Carolina State University, United States
- University of California-Santa Barbara, United States
- Tokyo University of Agriculture and Technology (TUAT), Japan
- RIKEN, Japan
- Nagoya University, Japan
- Meijo University, Japan
- National Institute of Advanced Industrial Science and Technology (AIST), Japan
- Collaborative Research in Engineering, Science and Technology (CREST), Malaysia
- Universiti Malaya, Malaysia
- Industrial Technology Research Institute (ITRI), Taiwan



UR26K Production GaN MOCVD System



TAIYO NIPPON SANSO

MOCVD Website



<https://www.mocvd.jp/en/>

Innovation Website



<https://www.tnsc-innovation.com/>

YouTube Channel



<https://m.youtube.com/channel/UC23pJTKDef-nbxUxbcjiHeQ>